



*Idw*

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:	§	Attorney Docket No. 24061.142
Ai-Sen Liu et al.	§	(2002-1387)
	§	
Serial No.: 10/657,847	§	Customer No. 42717
	§	
Filed: September 9, 2003	§	Group Art Unit: 2822
	§	
For: METHOD FOR FORMING	§	Examiner: Duong, Khanh B.
DIELECTRIC BARRIER LAYER	§	
IN DAMASCENE STRUCTURE	§	

**RESPONSE**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the non-final Office Action mailed May 4, 2005, please reconsider the application in light of the following amendments and remarks:

**Amendments to the Claims** begin on page 2 of this paper.

**Remarks** begin on page 17 of this paper.